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Application Serial No. 10/678,513  
Response to October 19, 2004 OA

MI22-2391

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Application Serial No. .... 10/678,513  
Filing Date ..... October 3, 2003  
Inventor ..... Werner Juengling  
Assignee ..... Micron Technology, Inc.  
Group Art Unit ..... 2823  
Examiner ..... Brook Kebede  
Attorney's Docket No. .... MI22-2391  
Title: Semiconductor Processing Methods Of Forming A Contact Opening To A  
Conductive Line and Methods of Forming Substrate Active Area  
Source/Drain Regions

**RESPONSE TO OCTOBER 19, 2004 OFFICE ACTION**

To: Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

From: D. Brent Kenady  
Tel. 509-624-4276; Fax 509-838-3424  
Wells St. John P.S.  
601 W. First Avenue, Suite 1300  
Spokane, WA 99201-3817

Responsive to the Office Action dated October 19, 2004, Applicant amends  
and remarks as follows:

**AMENDMENTS**

Underlines indicate insertions and ~~strikeouts~~ indicate deletions.